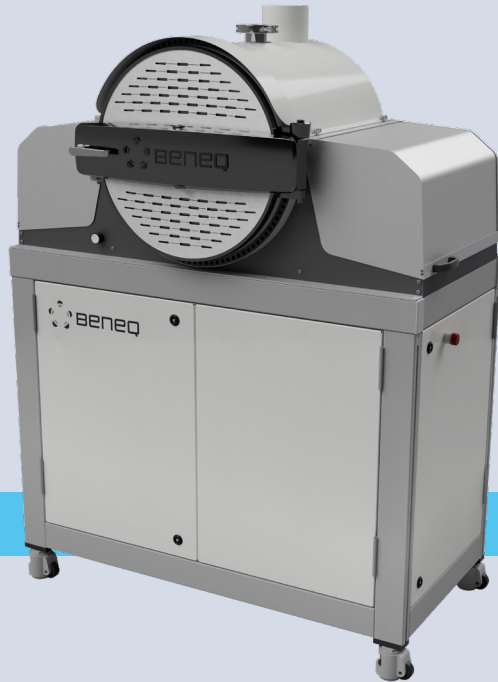


BENEQ R2



BENEQ R2

Compact. Scalable.
Perfect for your start with ALD.

- A premium ALD reactor packaged in a compact enclosure
- Ergonomically designed from the ground up with focus on performance and ease of use
- Modular design allows for quick upgrades and maintenance

BENEQ R2

PROCESS TYPE

- Thermal ALD
- Plasma ALD

USAGE

- Academic research
- Corporate R&D

SUBSTRATE TYPE

- Up to 200 mm wafers
- 3D parts

SUBSTRATE LOADING

- Ergonomically designed for manual loading

MAIN DIMENSIONS

- 1200x805x1630 mm

INTEGRATION

- All main components and electrical box integrated inside the tool frame

For product inquiries, please contact:

ald-sales@beneq.com

Technical information in this document is subject to change without notice. 3/2021

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